

2009 FEB 27 AM 11: 39

Electronically Filed February 26, 2009

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application of:	SENZAKI, Yoshihide	Confirmation No.:	3254
Serial No.:	10/524,980	Art Unit:	2823
Filed:	March 22, 2006	Examiner:	LEE, Hsien Ming
For:	<i>Low Temperature Deposition of Silicon Oxides and Oxynitrides</i>	Attorney Docket No:	067538-5172-US

**ASSERTION OF SMALL ENTITY STATUS UNDER 37 C.F.R. § 1.27(c)  
AND REQUEST FOR REFUND UNDER 37 C.F.R. § 1.28(a).**

Mail Stop 16  
Director of the U.S. Patent and Trademark Office  
P.O. Box 1450  
Alexandria, VA 22313-1450.

Dear Commissioner:

The Assignee of above application hereby asserts small entity status in accordance with 37 C.F.R. § 1.27(c). Applicants are, therefore, entitled to pay reduced fees in connection with this application. A Verified Statement (Declaration) Claiming Small Entity Status is enclosed herewith.

Under 37 C.F.R. § 1.28(a), Applicants may file a request for a refund of any excess fees paid within three months of the payment of the full fee.<sup>1</sup> Applicants hereby request a refund of the excess fees paid in connection with the above application as follows:

On December 12, 2008, Applicants filed a (1) Request for Continued Examination and (2) a Petition for Extension of Time of three months and paid large entity fees totaling of \$1920.00 in connection with this filing. Applicants hereby request a refund of \$960.00 (the excess amount paid).

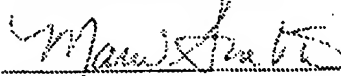
<sup>1</sup> 37 C.F.R. § 1.28(a) ("A refund pursuant to § 1.26, based on establishment of small entity status, of a portion of fees timely paid in full prior to establishing status as a small entity may only be obtained if an assertion under § 1.27(c) and a request for a refund of the excess amount are filed within three months of the date of the timely payment of the full fee.")

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Please credit the refund to Morgan, Lewis & Bockius LLP Deposit Account No. 50-0310  
(order no. 067538-5172-US).

Respectfully submitted,

Date: February 26, 2009



37,244

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## Electronic Patent Application Fee Transmittal

**Application Number:**

10524980

**Filing Date:**

22-Mar-2006

Adjustment date: 03/09/2009 HDESTA1  
12/15/2008 INTEFSW 00003918 500310 10524980  
01 FC:1253 1110.00 CR  
02 FC:1801 810.00 CR

**Title of Invention:**

Low temperature deposition of silicon oxides and oxynitrides

03/09/2009 HDESTA1 00000004 500310 10524980

01 FC:2253 555.00 DA  
02 FC:2801 405.00 DA

**First Named Inventor/Applicant Name:**

Yoshihide Senzaki

**Filer:**

Maria S. Swiatek/Vladimir Skliba

**Attorney Docket Number:**

067538-5172US

Filed as Large Entity

### U.S. National Stage under 35 USC 371 Filing Fees

Description	Fee Code	Quantity	Amount	Sub-Total in USD(\$)
<b>Basic Filing:</b>				
<b>Pages:</b>				
<b>Claims:</b>				
<b>Miscellaneous-Filing:</b>				
<b>Petition:</b>				
<b>Patent-Appeals-and-Interference:</b>				
<b>Post-Allowance-and-Post-Issuance:</b>				
<b>Extension-of-Time:</b>				
Extension - 3 months with \$0 paid	1253	1	1110	1110

Description	Fee Code	Quantity	Amount	Sub-Total in USD(\$)
<b>Miscellaneous:</b>				
Request for continued examination	1801	1	810	810
<b>Total in USD (\$)</b>				<b>1920</b>